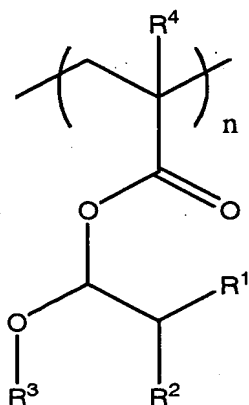


Abstract

The present invention provides a visible light-sensitive composition which is highly sensitive to a visible light and is useful as an electronic circuit forming material, a lithographic printing material, etc., said visible light-sensitive composition comprising (a) a polymer comprising a repeating unit represented by general formula (I):



(I)

10 wherein R¹, R², and R³ are the same or different and each represents substituted or unsubstituted alkyl, substituted or unsubstituted aryl, or substituted or unsubstituted aralkyl, or alternatively R¹ and R² form cycloalkyl together with the adjacent carbon atom, and R⁴ represents lower alkyl,
15 (b) a compound that generates an acid by visible light irradiation and (c) a sensitizing dye.